	Туре	Hits	Search Text	DBs	Time Stamp	o m m e nt	ef	Er ro rs
1	BRS	98	(cetyltrimethylammonium adj (bromide or chloride or Br or Cl or fluoride or F or halide)) and polish\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/07 16:22			0
2	BRS	47	(cetyltrimethylammonium adj (bromide or chloride or Br or Cl or fluoride or F or halide)) and polish\$31 and @pd<=20001130	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/07 16:26			0
3	BRS	0	((cetyltrimethylammonium adj (bromide or chloride or Br or Cl or fluoride or F or halide)) and polish\$31 and @pd<=20001130) not ((cetyltrimethylammonium adj (bromide or chloride or Br or Cl or fluoride or F or halide)) and polish\$3)	EPO; JPO; DERWENT;	2003/02/07 16:27			0
4	BRS	51	((cetyltrimethylammonium adj (bromide or chloride or Br or Cl or fluoride or F or halide)) and polish\$3) not ((cetyltrimethylammonium adj (bromide or chloride or Br or Cl or fluoride or F or halide)) and polish\$31 and @pd<=20001130)	EPO; JPO;	2003/02/07 16:30			)

1 BRS L1 10 (cmp or "chemical mechanical polishing") and (("citric acid salt" or "potassium citrate") same ("H.sub.2 O.sub.2" or peroxide or "hydrogen peroxide"))  USPAT; US-PGPUB; EPO; JPO; DERWENT; 17:58		Туре	L#	Hits	Search Text	DBs	Time Stamp	o m m	ef in	Er ro rs
L I I I I I I I I I I I I I I I I I I I	1	BRS	L1		and (("citric acid salt" or "potassium citrate") same ("H.sub.2 O.sub.2" or	<b>US-PGPUB:</b>	2003/07/02 17:58			0

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	Туре	e L#	Hits	Search Text	DBs	Time Stamp	m e	ef	Er ro
1	BRS	L1	51	((typical or conventional) with (slurry) with (pH)) same (cmp or "chemical mechanical polishing")	USPAT; US-PGPUB EPO; JPO; DERWENT; IBM_TDB	, 2003/07/03 11:58			0
2	BRS	L8	21	(MW or "molecular weight") with ("potassium citrate")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/07/03 12:18			0
3	BRS	L15	3616	(commercial\$2 with (peroxide or "H=sub.2 O.sub.2"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/07/03 12:22		***************************************	0
4	BRS	L22	71	15 and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/07/03 12:38			)
5	BRS	L29	110	("precipitated" adj2 (abrasive or (silica or ("SiO.sub.2")))) and (CMP or "chemical mechanical polishing")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/07/03 12:38		C	)
6	BRS	L36	36	29 and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/07/03 12:38		0	

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